# 1998 Semi-Annual Reliability Report (compiled 10/98)

## INTRODUCTION

*Quality Comes First*

By adhering to this guiding value, Microchip Technology Inc. has achieved competitive leadership in quality and reliability for its products. Demonstrated performance levels of less than 100 Failures in Time (FITS) for most products have been realized through the design-in of reliability and continued use of reliability monitors.

This report details Microchip's quality and reliability systems as well as presenting data on the results of these systems. It includes the following:

- Reliability Control System
- Failure Calculation Methodology
- Reliability Test Descriptions
- 1998 Product Reliability

## RELIABILITY CONTROL SYSTEM

A comprehensive qualification system is employed to ensure that released products are designed, processed, packaged, and tested to meet both design functionality and performance, and strict reliability objectives. Once qualified, a reliability monitor system ensures that wafer fabrication and assembly process performance is stable over time. A set of baseline specifications is maintained that states which changes require requalification. These process changes can only be made after successful demonstration of reliability performance. This system results in reliable field performance, while enabling the smooth phase-in of improved designs and product capability. The system is diagrammed in Table 1.

**TABLE 1: RELIABILITY CONTROL SYSTEM DIAGRAM**

| DESIGN AND DEVELOPMENT | QUALIFICATION | RELIABILITY CONTROL |
|---|---|---|
| **Specify:**<br>• Design objectives/ specifications<br>• Testability goals<br>• Reliability requirements<br>• Process/packaging requirements<br>• Design guidelines<br>**Design:**<br>• Functional models<br>• Logic design and verification<br>• Circuit design and verification<br>• Layout design and verification<br>• Prototype verification<br>• Performance characterization<br>**Develop (as required):**<br>• Wafer fabrication processes<br>• Package/packaging technology | **Confirm Design Objectives Using Qualification Tests:**<br>• Operating life, 125°C ambient<br>• Temp-cycle, -65°/150°C<br>• Thermal shock, -55°/125°C<br>• ESD, volts HBM ± 4000<br>• ESD, volts MM ±400<br>• Latch-up (CMOS devices)<br>• HAST 130°C/85%<br>• Autoclave (pressure cooker)<br>• Retention bake,150°C ambient | **Assure Outgoing Quality Level:**<br>• Design release document<br>• Baseline wafer fabrication process<br>• Baseline assembly process<br>• Qualification release<br>• Enter device to specification system<br>• Wafer-level reliability controls<br>• Assembly reliability controls<br>• Early failure rate sampling<br>• Reliability monitoring<br>• Statistical process control feedback<br>• Audit specifications<br>• Analyze returned failures<br>• Requalify devices as needed for major changes such as ESD resistance enhancement, cost reduction/die shrink, process improvement and new package types |

## FAILURE RATE CALCULATION

FIT (Failure in Time): Expresses the estimated field failure rate in number of failures per billion device hours. 100 FITS equals 0.01% fail per 1,000 device hours.

Extended field life is simulated by using high ambient temperature. In the semiconductor technology, high temperatures dramatically accelerate the mechanisms leading to component failure. Using performance results at different temperatures, an activation energy is determined using the Arrhenius Equation. For each type of failure mechanism, the activation energy expresses the degree to which temperature increases the failure rate.

The activation energy values determined by Microchip agree closely with those published in the literature. For complex CMOS devices in production at Microchip, an activation energy of 0.6 eV has been shown to be representative of typical failures on operating life. By definition, failure is reached when a device no longer meets the data sheet specifications as a direct result of the reliability test environment to which it was exposed. Common failure modes for CMOS integrated circuits are identified for each test environment.

To establish a field failure rate, the acceleration factor is applied to the device operating hours observed at high temperature stress and extrapolated to a failure rate at 55°C ambient temperature in still air.

The actual failure rate experienced could be considerably less than that calculated if lower device temperatures occur in the application board, such as would be the case if a fan, a heat sink or air flow by convection is used.

| Environment | Attribute Tested |
|---|---|
| Operating Life | Process parameter drift/shift |
| | Metal electromigration |
| | Internal leakage path |
| | Data retention |
| | Bond/ball bond integrity |
| Temperature Cycle | Bond/ball integrity |
| | Die or surface integrity |
| | Bond pad integrity |
| Biased-Humidity | Internal device leakage |
| | Corrosion resistance |
| PCT | Inter-pin leakage |
| | Data retention |
| | Corrosion resistance |
| High Temp. Bake | Data retention |

## RELIABILITY TEST DESCRIPTIONS

### High Temperature (125°C) Dynamic Life Test

High temperature dynamic life testing accelerates random failure modes which could occur in user applications. Voltage bias and address signals are used to exercise the device in a manner similar to user systems. The voltage maintained during the tests is at or near the maximum data sheet voltage supply. Derating from high temperature, an ambient use condition failure rate can be calculated. The extrapolation of data for FIT rate purposes of this test does not include electrical acceleration.

### Temperature Cycle

The devices are exposed to severe extremes of temperature in an alternating fashion (-65°C for 10 minutes, 150°C for 10 minutes per cycle). Package strength, bond quality and consistency of assembly process are stressed using this environment.

### PCT (Pressure Cooker or Autoclave)

Using a pressure of one atmosphere above atmospheric pressure, plastic packaged devices are exposed to moisture at 121°C. The pressure forces moisture permeation of the package and accelerates related failure mechanisms, if present, on the device.

### Thermal Shock

Exposes devices to extreme temperatures from -55°C to +125°C by alternate immersion in liquid media. This is a sudden temperature change, as opposed to the gradual change in the Temperature Cycling test. Otherwise, it induces the same stresses as Temperature Cycling.

### Data Retention Bake

A 125°C temperature stress is used to accelerate charge loss in the memory cell and measure the data retention on the EPROM and EEPROM portions of the circuitry.

Data storage in applicable devices is done by developing a charge on the floating gate structure in the memory cell. Charge loss in this cell structure results in a conversion of data states. In order to evaluate the level of this type of failure, devices are subjected to a 150°C bake. This bake accelerates charge loss in the memory cell and 1000 hours at 150°C is equivalent to greater than 25 years in the field at 55°C.

### Highly Accelerated Stress Test (HAST)

Moisture, extreme heat and bias are used to accelerate corrosion and contamination in plastic packages. The conditions are 130°C and 85% relative humidity. Typical bias voltage is +5 V and ground on alternating pins.

## Erase/Write Endurance of EEPROMs

### Measurement of Cycling

Microchip defines a device lifetime in the strictest sense, that is, stated lifetime has to exhibit the truest correlation to customer results. An endurance failure is determined when any one bit in the array is not capable of being correctly written and maintained in that state indefinitely.

The device lifetime is defined when a specified percentage of devices (Microchip currently uses a cumulative 2.5 percent) have a customer detectable error under worst case operating conditions.

Ongoing monitors are acquired from wafer lots of material manufactured for shipment. Samples are subjected to page cycling of an alternating checkerboard and inverse checkerboard pattern at 85°C in rapid succession to a specified number of cycles. These units then are baked at 150°C for 48 hours in both checkerboard and inverse checkerboard states and electrically tested to ensure that data sheet requirements are met. This data is accumulated on a monthly basis and reviewed to measure both results of continuous improvement programs and conformance to the device standards.

### Endurance Variables

a) **Temperature:** Within the FLOTOX technology, temperature has an inverse effect on the endurance of a EEPROM device. The activation energy of these cycling failures is approximately 0.15 eV. The long term trap up portion of the curve is worsened by temperature to a greater extent than the early fails due to the difficult failure mechanisms that are activated.

b) **Delay Between Cycles:** This has been reported in the industry as having an enhanced effect on the lifetime of EEPROM devices. For some technologies, this does have a positive effect; however, this is not strictly the case for FLOTOX manufacturers. While the second failure rate increase period (associated with end of life) may be impacted by this due to a decreased rate of electron trapping, the first failure rate is actually not impacted by this variable.

c) **Write Timing:** The decrease in write time to the device correlates directly with the write/erase cycling failure rate of the device. This shorter pulse reduces the cell time at voltage which then provides an enhanced life prior to the occurrence of a time dependent oxide breakdown. It also passes fewer electrons through the oxide providing less potential trapping possibilities while maintaining adequate margins for the written state.

| | |
|---|---|
| **Note:** | The rise time of the signal, which the customer does not have control over, is also a dominant effect. |

d) **VCC Voltage:** The higher voltages generate higher fields within the device. This causes more stress which is offset by the operational increase of internal timers and actually shortens the write time of the device.

Lower voltages have the opposite effect on the individual parameters except in cycles obviously where the write timer is externally controlled. This overall effect is minor compared to the others in magnitude on the failure rate curve and is variable over the customer operating range with a maximum at VCC = 5.5 V.

e) **Pattern Effect:** The pattern that is programmed in the device does play a first order role in the overall lifetime. The act of programming a non-volatile memory inflicts damage on the device that cannot be repaired. This damage is the result of exposure to high electric fields which over a period of time either breakdown or trap up the effected oxide causing failures. The act of writing a cell from a one to a zero provides the maximum amount of stress by exercising the charge pump and passing electrons through the tunnel dielectric.

| | |
|---|---|
| **Note:** | To write a zero even from a zero state causes an automatic byte erase prior to the write converting the bit to a one and returning it to its original state!<br><br>Conversely writing a one from a one then passes no charge through the cell and, therefore, does no damage to the cell but does stress the charge pump.<br>From an array standpoint, this would allow a checkerboard/ inverse checkerboard patterned device to endure twice the number of write cycles of an all zero patterned device. In general, this appears to be approximately correct but does neglect the charge pump and other peripheral wear-out mechanisms. |

**Cycling Mode:** Three modes exist in Microchip devices that are primarily used for endurance evaluations. The byte write mode (one single byte written at a time) is the standard mode used by the customer in the field as well as the method of monitoring that has been chosen internally. This is to best estimate field lifetime expectations and actual failure rates. A second technique exists called block mode which exercises all the cells of the array simultaneously. The failure rates of byte cycled devices are approximately two times the failure rates of block cycled devices according to experimental test data. This effect has been traced back to the rise time of the programming signal at the memory cell. The faster this voltage rise occurs, the more damage occurs and the shorter the lifetime. The block mode has a much slower rise time given the entire array being utilized provides a much larger resistive/capacitive load which slows the signal rise ultimately resulting in the greater lifetime. Please note that the page mode which can be utilized by the customers falls between the block and byte modes with respect to failure rate.

f) **Array Size:** This effect is a direct result of how fast most devices will fail due to a single bit not working simply due to the number of bits involved. This is not exactly double the failure rate with a doubling of the memory size since some circuits fail within the charge pump or decoding circuitry sections and are, therefore, not directly related to array size.

### Field Results

After significant experimentation, Microchip has developed a model of the endurance failure rates as a function of all the variables listed above. This model is available to the customer in the form of a diskette called Total Endurance™. The Total Endurance Software Model allows the customer to bypass confusing information and conditions other than their application and directly predict the failure rate in their application conditions within a few percent. This also allows the customer to adjust operating parameters and immediately evaluate the impact on the results of the final system.

## RELIABILITY DATA SUMMARY

The following section provides a reliability summary of Microchip's product. Included is reliability data and packaging information obtained during 1998.

# SUMMARY OF RELIABILITY – 1998 SEMI-ANNUAL REPORT DEVICE DATA

## I. DYNAMIC LIFE/ RETENTION BAKE

**Dynamic Life**

| | | | | | |
|---|---|---|---|---|---|
| Stress Temperature: | 125°C | Activation Energy: | 0.6 | eV | 57K, 77K |
| Derated Temperature: | 55°C | Acceleration Rate: | 42 | | |
| | | Activation Energy: | 0.7 | eV | 90K |
| | | Acceleration Rate: | 78 | | |

**Retention Bake**

| | | | | | |
|---|---|---|---|---|---|
| Stress Temperature: | 150°C | Activation Energy: | 0.6 | eV | 57K EPROM |
| Derated Temperature: | 55°C | Acceleration Rate: | 117 | | |
| | | Activation Energy: | 1.2 | eV | 57K EE, 77K, |
| | | Acceleration Rate: | 13718 | | & 90K |

**Microcontrollers** — **Fit Rates, 60% Confidence Level**

| Device | Operation | 168 Hrs. | 1008 Hrs. | Fails | Device Hrs. | Infant Mortality | Long Term Life | Total Life |
|---|---|---|---|---|---|---|---|---|
| ALL PICS | Dynamic Life | 3/9753 | 0/4524 | 3 | 5,438,664 | 36 | 3 | 11 |
| | Retention Bake | 2/14334 | 0/3164 | 2 | 5,065,872 | <1 | <1 | <1 |
| ALL 90k PICS | Dynamic Life | 3/7794 | 0/3538 | 3 | 4,281,312 | 48 | 5 | 15 |
| | Retention Bake | 2/12195 | 0/2741 | 2 | 4,351,200 | <1 | <1 | <1 |
| ALL 77k PICS | Dynamic Life | 0/1543 | 0/778 | 0 | 912,744 | 85 | 34 | 24 |
| | Retention Bake | 0/1581 | 0/327 | 0 | 540,288 | <1 | <1 | <1 |
| ALL 57k PICS | Dynamic Life | 0/416 | 0/208 | 0 | 244,608 | 315 | 126 | 90 |
| | Retention Bake | 0/558 | 0/96 | 0 | 174,384 | 83 | 97 | 45 |
| PIC16C924 | Dynamic Life | 0/653 | 0/330 | 0 | 386,904 | 108 | 43 | 31 |
| | Retention Bake | 0/1041 | 0/209 | 0 | 350,448 | <1 | <1 | <1 |
| PIC16C622 | Dynamic Life | 0/309 | 0/190 | 0 | 211,512 | 227 | 74 | 56 |
| | Retention Bake | 0/1834 | 0/429 | 0 | 668,472 | <1 | <1 | <1 |
| PIC16C74A | Dynamic Life | 0/1138 | 0/486 | 0 | 599,424 | 62 | 29 | 20 |
| | Retention Bake | 0/1686 | 0/302 | 0 | 536,928 | <1 | <1 | <1 |
| PIC16C72 | Dynamic Life | 0/807 | 0/286 | 0 | 375,816 | 87 | 49 | 31 |
| | Retention Bake | 0/948 | 0/206 | 0 | 332,304 | <1 | <1 | <1 |
| PIC16C66/67/68 | Dynamic Life | 3/1142 | 0/570 | 3 | 670,656 | 280 | 25 | 80 |
| | Retention Bake | 2/1626 | 0/397 | 2 | 606,648 | 1 | <1 | <1 |
| PIC16C63/65A | Dynamic Life | 0/1126 | 0/486 | 0 | 597,408 | 62 | 29 | 20 |
| | Retention Bake | 0/1429 | 0/315 | 0 | 504,672 | <1 | <1 | <1 |
| PIC16C62A/64A | Dynamic Life | 0/810 | 0/324 | 0 | 408,240 | 87 | 43 | 29 |
| | Retention Bake | 0/925 | 0/205 | 0 | 327,600 | <1 | <1 | <1 |
| PIC16C58A | Dynamic Life | 0/634 | 0/380 | 0 | 425,712 | 111 | 37 | 28 |
| | Retention Bake | 0/1685 | 0/315 | 0 | 547,680 | <1 | <1 | <1 |
| PIC16C57 | Dynamic Life | 0/403 | 0/208 | 0 | 242,424 | 325 | 126 | 91 |
| | Retention Bake | 0/512 | 0/112 | 0 | 180,096 | 1 | 1 | <1 |
| PIC16C55 | Dynamic Life | 0/416 | 0/208 | 0 | 244,608 | 315 | 126 | 90 |
| | Retention Bake | 0/558 | 0/96 | 0 | 174,384 | 83 | 97 | 45 |
| PIC16C54 | Dynamic Life | 0/1140 | 0/570 | 0 | 670,320 | 115 | 46 | 33 |
| | Retention Bake | 0/1069 | 0/215 | 0 | 360,192 | <1 | <1 | <1 |
| PIC17C44 | Dynamic Life | 0/1175 | 0/486 | 0 | 605,640 | 60 | 29 | 19 |
| | Retention Bake | 0/1021 | 0/363 | 0 | 476,448 | <1 | <1 | <1 |

Failure Modes: Dynamic Life — 3 units of PIC16C67 failed due to high sleep current
Retention Bake — 2 units of PIC16C67 failed due to high sleep current

| Serial EEPROMS | | | | | Fit Rates, 60% Confidence Level | | | |
|---|---|---|---|---|---|---|---|---|
| **Device** | **Operation** | **168 Hrs.** | **1008 Hrs.** | **Fails** | **Device Hrs.** | **Infant Mortality** | **Long Term Life** | **Total Life** |
| ALL SERIAL | Dynamic Life | 2/15925 | 1/6555 | 3 | 8,181,600 | 28 | 9 | 12 |
| EEPROMS | Retention Bake | 15/20184 | 0/4179 | 15 | 6,901,272 | <1 | <1 | <1 |
| 57k SERIAL | Dynamic Life | 2/774 | 0/320 | 2 | 398,832 | 573 | 82 | 187 |
| EEPROMS | Retention Bake | 0/1003 | 0/212 | 0 | 346,584 | <1 | <1 | <1 |
| 77k SERIAL | Dynamic Life | 0/15151 | 1/6235 | 1 | 7,782,768 | 9 | 9 | 6 |
| EEPROMS | Retention Bake | 15/19181 | 0/3967 | 15 | 6,554,688 | <1 | <1 | <1 |
| 24C04 | Dynamic Life | 2/774 | 0/320 | 2 | 398,832 | 573 | 82 | 187 |
| | Retention Bake | 0/1003 | 0/212 | 0 | 346,584 | <1 | <1 | <1 |
| 93LC46 | Dynamic Life | 0/1175 | 0/480 | 0 | 600,600 | 111 | 55 | 37 |
| | Retention Bake | 0/505 | 0/100 | 0 | 168,840 | 1 | 1 | <1 |
| 93LC56/66 | Dynamic Life | 0/2334 | 0/960 | 0 | 1,198,512 | 56 | 27 | 18 |
| | Retention Bake | 0/3013 | 0/612 | 0 | 1,020,264 | <1 | <1 | <1 |
| 93LC86 | Dynamic Life | 0/388 | 0/160 | 0 | 199,584 | 337 | 164 | 110 |
| | Retention Bake | 0/0 | 0/0 | 0 | 0 | N/A | N/A | N/A |
| 24LC01B | Dynamic Life | 0/388 | 0/160 | 0 | 199,584 | 337 | 164 | 110 |
| | Retention Bake | 0/1513 | 0/300 | 0 | 506,184 | <1 | <1 | <1 |
| 24LC02B | Dynamic Life | 0/1938 | 0/800 | 0 | 997,584 | 68 | 33 | 22 |
| | Retention Bake | 0/4064 | 0/871 | 0 | 1,414,392 | <1 | <1 | <1 |
| 24LC04B | Dynamic Life | 0/1946 | 0/795 | 0 | 994,728 | 67 | 33 | 22 |
| | Retention Bake | 0/2536 | 0/536 | 0 | 876,288 | <1 | <1 | <1 |
| 24LC08B | Dynamic Life | 0/783 | 0/320 | 0 | 400,344 | 167 | 82 | 55 |
| | Retention Bake | 0/1024 | 0/212 | 0 | 350,112 | <1 | <1 | <1 |
| 24LC16B | Dynamic Life | 0/1933 | 1/800 | 1 | 996,744 | 68 | 72 | 49 |
| | Retention Bake | 0/2028 | 0/424 | 0 | 696,864 | <1 | <1 | <1 |
| 24LC32A | Dynamic Life | 0/785 | 0/320 | 0 | 400,680 | 167 | 82 | 55 |
| | Retention Bake | 0/988 | 0/200 | 0 | 333,984 | <1 | <1 | <1 |
| 24LC65 | Dynamic Life | 0/1150 | 0/480 | 0 | 596,400 | 114 | 55 | 37 |
| | Retention Bake | 15/1507 | 0/300 | 15 | 505,176 | 5 | <1 | 2 |
| 24LCS21 | Dynamic Life | 0/1144 | 0/480 | 0 | 595,392 | 114 | 55 | 37 |
| | Retention Bake | 0/991 | 0/212 | 0 | 344,568 | <1 | <1 | <1 |
| 24LCS52 | Dynamic Life | 0/787 | 0/320 | 0 | 401,016 | 166 | 82 | 55 |
| | Retention Bake | 0/1012 | 0/200 | 0 | 338,016 | <1 | <1 | <1 |
| 25LC08/16/162 | Dynamic Life | 0/400 | 0/160 | 0 | 201,600 | 327 | 164 | 109 |
| | Retention Bake | 0/0 | 0/0 | 0 | 0 | N/A | N/A | N/A |
| Failure Modes: | Dynamic Life | 1 unit of 24LC16B failed due to high standby current<br>1 unit of 24C04 failed due to high standby current<br>1 unit of 24C04 failed functionality | | | | | | |
| | Retention Bake | 15 units of 24LC65 failed due to single bit charge loss | | | | | | |

| Parallel EEPROMs | | | | | Fit Rates, 60% Confidence Level | | | |
|---|---|---|---|---|---|---|---|---|
| **Device** | **Operation** | **168 Hrs.** | **1008 Hrs.** | **Fails** | **Device Hrs.** | **Infant Mortality** | **Long Term Life** | **Total Life** |
| ALL PARALLEL EEPROMS | Dynamic Life | 0/394 | 0/160 | 0 | 200,592 | 332 | 164 | 110 |
| | Retention Bake | 0/997 | 0/200 | 0 | 335,496 | <1 | <1 | <1 |
| 28C64 | Dynamic Life | 0/394 | 0/160 | 0 | 200,592 | 332 | 164 | 110 |
| | Retention Bake | 0/997 | 0/200 | 0 | 335,496 | <1 | <1 | <1 |
| Failure Modes: | Dynamic Life | N/A | | | | | | |
| | Retention Bake | N/A | | | | | | |

| EPROMs | | | | | Fit Rates, 60% Confidence Level | | | |
|---|---|---|---|---|---|---|---|---|
| **Device** | **Operation** | **168 Hrs.** | **1008 Hrs.** | **Fails** | **Device Hrs.** | **Infant Mortality** | **Long Term Life** | **Total Life** |
| ALL EPROMS | Dynamic Life | 4/797 | 0/353 | 4 | 430,416 | 659 | 50 | 200 |
| | Retention Bake | 0/939 | 0/200 | 0 | 325,752 | <1 | <1 | <1 |
| ALL 90k EPROMS | Dynamic Life | 4/392 | 0/193 | 4 | 227,976 | 1024 | 73 | 296 |
| | Retention Bake | 0/473 | 0/100 | 0 | 163,464 | 1 | 1 | <1 |
| ALL 77k EPROMS | Dynamic Life | 0/405 | 0/160 | 0 | 202,440 | 323 | 164 | 109 |
| | Retention Bake | 0/466 | 0/100 | 0 | 162,288 | 1 | 1 | <1 |
| 27C256 | Dynamic Life | 0/405 | 0/160 | 0 | 202,440 | 323 | 164 | 109 |
| | Retention Bake | 0/466 | 0/100 | 0 | 162,288 | 1 | 1 | <1 |
| 27C512A | Dynamic Life | 4/392 | 0/193 | 4 | 227,976 | 1024 | 73 | 296 |
| | Retention Bake | 0/473 | 0/100 | 0 | 163,464 | 1 | 1 | <1 |
| Failure Modes: | Dynamic Life | 4 units of 27C512 failed due to single bit charge loss | | | | | | |
| | Retention Bake | N/A | | | | | | |

| Secure Data Products | | | | | Fit Rates, 60% Confidence Level | | | |
|---|---|---|---|---|---|---|---|---|
| **Device** | **Operation** | **168 Hrs.** | **1008 Hrs.** | **Fails** | **Device Hrs.** | **Infant Mortality** | **Long Term Life** | **Total Life** |
| ALL SECURE DATA PRODUCTS | Dynamic Life | 0/1152 | 0/1152 | 0 | 1,161,216 | 114 | 23 | 19 |
| | Retention Bake | 0/0 | 0/0 | 0 | 0 | N/A | N/A | N/A |
| HCS301 | Dynamic Life | 0/768 | 0/768 | 0 | 774,144 | 170 | 34 | 28 |
| | Retention Bake | 0/0 | 0/0 | 0 | 0 | N/A | N/A | N/A |
| HCS360 | Dynamic Life | 0/384 | 0/384 | 0 | 387,072 | 341 | 68 | 57 |
| | Retention Bake | 0/0 | 0/0 | 0 | 0 | N/A | N/A | N/A |
| | Dynamic Life | N/A | | | | | | |
| | Retention Bake | N/A | | | | | | |

## II. PRESSURE COOKER, HAST, TEMPERATURE CYCLE, AND THERMAL SHOCK PACKAGE DATA SUMMARY

**Pressure Cooker**

| | | | |
|---|---|---|---|
| Stress Temperature: | 121.5°C | Activation Energy: | 0.6 eV |
| Derated Temperature: | 55°C | Acceleration Rate: | 36 |

**Hast**

| | | | |
|---|---|---|---|
| Stress Temperature: | 130°C | Activation Energy: | 0.6 eV |
| Derated Temperature: | 55°C | Acceleration Rate: | 52 |

| Operation | Package | 24 Hrs. | 168 Hrs. | Fails | Device Hrs. | % fails per 1000 hrs. |
|---|---|---|---|---|---|---|
| Pressure Cooker | ALL PACKAGES | 0/15400 | 2/15393 | 2 | 2,586,192 | 0.10 |
| Pressure Cooker | MQFP | 0/1400 | 0/1397 | 0 | 234,768 | 0.30 |
| Pressure Cooker | PDIP | 0/5300 | 0/5298 | 0 | 890,112 | 0.08 |
| Pressure Cooker | PLCC | 0/1300 | 0/1300 | 0 | 218,400 | 0.32 |
| Pressure Cooker | SOIC | 0/7300 | 2/7298 | 2 | 1,226,112 | 0.22 |
| Pressure Cooker | SOT | 0/50 | 0/50 | 0 | 8,400 | 8.25 |
| Pressure Cooker | TSOP | 0/50 | 0/50 | 0 | 8,400 | 8.25 |
| Failure Modes: | 1 unit of 8L SOIC (24LC65) failed due to single byte data disturbance<br>1 unit of 8L TSSOP (24LCS52) failed to program | | | | | |

| Operation | Package | 48 Hrs. | 168 Hrs. | Fails | Device Hrs. | % fails per 1000 hrs. |
|---|---|---|---|---|---|---|
| HAST | ALL PACKAGES | 0/10321 | 0/10297 | 0 | 1,731,048 | 0.04 |
| HAST | MQFP | 0/838 | 0/830 | 0 | 139,632 | 0.50 |
| HAST | PDIP | 0/3509 | 0/3509 | 0 | 589,512 | 0.12 |
| HAST | PLCC | 0/810 | 0/810 | 0 | 136,080 | 0.51 |
| HAST | SOIC | 0/4870 | 0/4855 | 0 | 816,360 | 0.08 |
| HAST | SOT | 0/30 | 0/30 | 0 | 5,040 | 13.80 |
| HAST | TSOP | 0/264 | 0/263 | 0 | 44,232 | 1.57 |
| Failure Modes: | N/A | | | | | |

| Operation | Package | 50 Cyc. | 100 Cyc. | Fails |
|---|---|---|---|---|
| Temp. Cycles | ALL PACKAGES | 0/10 | 1/3492 | 1 |
| Temp. Cycles | MQFP | 0/0 | 0/270 | 0 |
| Temp. Cycles | PDIP | 0/0 | 0/1316 | 0 |
| Temp. Cycles | PLCC | 0/0 | 0/260 | 0 |
| Temp. Cycles | SOIC | 0/0 | 1/1626 | 1 |
| Temp. Cycles | SOT | 0/10 | 0/10 | 0 |
| Temp. Cycles | TSOP | 0/0 | 0/10 | 0 |
| Failure Modes: | 1 unit of 18L SOIC (PIC16C54A) failed functionality at $V_{DDHI}$ | | | |

| Operation | Package | 100 Cyc. | 500 Cyc. | Fails |
|---|---|---|---|---|
| Thermal Shock | ALL PACKAGES | 0/3452 | 0/10 | 0 |
| Thermal Shock | MQFP | 0/270 | 0/0 | 0 |
| Thermal Shock | PDIP | 0/1276 | 0/0 | 0 |
| Thermal Shock | PLCC | 0/260 | 0/0 | 0 |
| Thermal Shock | SOIC | 0/1626 | 0/0 | 0 |
| Thermal Shock | SOT | 0/10 | 0/10 | 0 |
| Thermal Shock | TSOP | 0/10 | 0/0 | 0 |
| Failure Modes: | N/A | | | |

**NOTES:**

**NOTES:**

# WORLDWIDE SALES AND SERVICE

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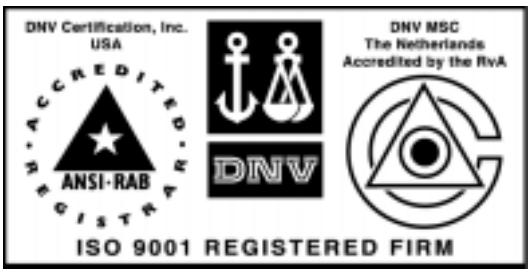


*Microchip received ISO 9001 Quality System certification for its worldwide headquarters, design, and wafer fabrication facilities in January, 1997. Our field-programmable PICmicro® 8-bit MCUs, Serial EEPROMs, related specialty memory products and development systems conform to the stringent quality standards of the International Standard Organization (ISO).*